



PATENT ATTORNEY DOCKET NO.: 46884-5429

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
Seiichi NAGATA	Confirmation No.: 4585
Application No.: 10/551,195	Group Art Unit: 2812
Filed: April 27, 2007	Examiner: Unassigned
For: SILICON SUBSTRATE AND FORMING METHOD THEREOF (As Amended))))

MAIL STOP PCT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

PRELIMINARY AMENDMENT

Prior to examination on the merits, please amend the above-identified application as follows.